MRD 5-10-99

REC(

05-20-1999 

HEET

Docket No. 990299/HG

101039963

To the Honorable Commissioner of Patents and Trademarks: Please record the attached original documents or copy thereof.

Name of conveying party(ies):

Hideto GOTOH Tsuyoshi MATSUI Takayuki NIUYA Tetsuo AOYAMA Taketo MARUYAMA Tetsuya KARITA Kojiro ABE Fukusaburou ISHIHARA Ryuji SOTOAKA

- 2. Name and address of receiving party(ies):
- 1. MITSUBISHI GAS CHEMICAL COMPANY, INC. 5-2, Marunouchi 2-chome, Chiyoda-ku o Tokyo, Japan
- TEXAS INSTRUMENTS INCORPORATED 2. 7839 Churchill Way, Mail Station 3999 Dallas, TX 75251, USA

Execution Date(s):	April 27, 1999	, April 2	7, 1999 ,,	April 27, 1999	<u>, April 30, 199</u>
April 30, 1999 ,	<u>April 30, 1999</u> ,	April 30, 1999 ,	April 30, 1999	, <u>April 30, 1999</u>	_, respectively.
	nber(s) or patent numl	,		ate of the application	is as follows:
April 27, 1999	, April	<u>27, 1999</u> ,	April 27, 1999	, April 30, 1999	_,
April 30, 1999 ,	April 30, 1999 ,	April 30, 1999 ,	April 30, 1999	, <u>April 30, 1999</u>	_, respectively.
A. Patent Application No. (s)			B. Patent No.(s)		
F 7	ress of party to whom RISHAUF, HOLTZ, G 67 Third Avenue, 2!	GOODMAN, LANGE 5th Floor		nould be mailed:	
F 7 N	RISHAUF, HOLTZ, G	GOODMAN, LANGE 5th Floor 10017-2023	R & CHICK, P.C.	nould be mailed: 7 CFR 3.41): \$ <u>40.0</u>	0
F 7 N	RISHAUF, HOLTZ, G 67 Third Avenue, 2! lew York, New York	GOODMAN, LANGE 5th Floor 10017-2023	R & CHICK, P.C.  7. Total fee (3)		
F 7 N	RISHAUF, HOLTZ, G 67 Third Avenue, 29 lew York, New York applications and patents i	GOODMAN, LANGE 5th Floor 10017-2023	R & CHICK, P.C.  7. Total fee (3)	7 CFR 3.41): \$ <u>40.0</u> ided with filing fee attac	<u> </u>
F 7 N 6. Total number of a	RISHAUF, HOLTZ, G 67 Third Avenue, 29 lew York, New York applications and patents i	GOODMAN, LANGE 5th Floor 10017-2023	7. Total fee (3	7 CFR 3.41): \$ <u>40.0</u> ided with filing fee attac	
6. Total number of a 7/1999 JSHABAZZ 00000	RISHAUF, HOLTZ, G 67 Third Avenue, 2! lew York, New York applications and patents i	GOODMAN, LANGE 5th Floor 10017-2023 involved: <u>1</u>	7. Total fee (3  [] Amount inclu  [X] Check enclo	7 CFR 3.41): \$ <u>40.0</u> Ided with filing fee attac sed.	hed hereto.
6. Total number of a 7/1999 JSHABAZZ 00000	RISHAUF, HOLTZ, G 67 Third Avenue, 29 lew York, New York applications and patents i 0101 09309076 40.00 QP t tendered by check, auth	GOODMAN, LANGE 5th Floor 10017-2023 involved: <u>1</u>	7. Total fee (3  [] Amount inclu  [X] Check enclo	7 CFR 3.41): \$ <u>40.0</u> Ided with filing fee attac sed.	hed hereto.
F 7 N 6. Total number of a 7/1999 JSHABAZZ 00000 2:581 8. To the extent not 9. Statement and sign	RISHAUF, HOLTZ, G 67 Third Avenue, 2! lew York, New York applications and patents i 0101 09309076 40.00 DP t tendered by check, auth gnature:	SOODMAN, LANGE 5th Floor 10017-2023 involved:1	7. Total fee (3 [] Amount inclu [X] Check enclo	7 CFR 3.41): \$ <u>40.0</u> Ided with filing fee attac sed.	thed hereto.

I hereby certify that this paper and enclosed application and fee are being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and is addressed to the Assistant Commissioner for Patents,

Total number of pages including cover sheet attendments and document: \_ 3\_

8/4/93

Date of Deposit: May 10, 1999

Washington, D.C. 20231.

## **ASSIGNMENT**

In consideration of value received, I, having a residence and post office address as stated below next to my name, the sole inventor (if only one name is listed below) or a joint inventor (if plural names are listed below) of an invention described in an application for United States patent entitled: CLEANING AGENT FOR USE IN PRODUCING SEMICONDUCTOR DEVICES AND PROCESS FOR PRODUCING SEMICONDUCTOR DEVICES USING THE SAME

sell and assign to (1) Mitsubishi Gas Chemical Company, Inc. (2) Texas Instruments Incorporated

a corporation of (1) Japan (2) U.S.A

having a business address at (1) 5-2, Marunouchi 2-chome, Chiyoda-ku, Tokyo, Japan (2) 7839 Churchill Way, Mail Station 3999 Dallas, TX 75251, USA its successors, assigns or nominees, hereinafter referred to as "Assignee", my entire right, title and interest in and to

its successors, assigns or nominees, hereinafter referred to as "Assignee", my entire right, title and interest in and to said invention as disclosed, shown and described in said application for United States patent executed concurrently herewith;

and in and to all applications for patent and patents for said invention, in all countries of the world, including all divisions, reissues, continuations, substitutions and extensions thereof and all rights arising under or pursuant to any and all international agreements, treaties or laws relating to the protection of industrial property, including rights of priority, resulting from the filing of any of said applications; and I authorize and request any official whose duty it is to issue patents, to issue any patent on said invention or resulting therefrom to said Assignee, and I agree that on request and without further consideration, but at the expense of said Assignee, I will communicate to said Assignee or its representatives all facts known to me respecting said invention and testify in any legal proceeding, sign all lawful papers, execute all divisional, continuing, reissue, or other applications, make all rightful oaths and declarations, and generally do everything possible to aid said Assignee to obtain and enforce proper patent protection for said invention in all countries.

I hereby grant to any attorney member of the following law firm the power to insert on this Assignment the Serial Number and filing date of said application when known.

**SERIAL NO.:** 

**FILING DATE:** 

**ADDRESS** 

Frishauf, Holtz, Goodman, Langer & Chick, P.C., 767 Third Avenue - 25th Floor, New York, N.Y. 10017-2023.

DATE

Sign: Date: Address: Klideto Gratak Apr. 27, 1999 21-6-102, Umezono 2-chome, Tsukuba-shi, Ibaraki-ken, Japan Witness: Hideto GOTOH Address: Sign: Apr. 27, 1999 c/o Texas Instruments Japan Ltd. 2350, Kihara, Miho-mura, Inashiki-gun, Ibaraki-ken, Japan Type: Witness: Tsuvoshi MATSUI Address: Sign: Date: 12-34, Kouyadai 3-chome, akuy Au, Apr. 27, 1999 Tsukuba-shi, Ibaraki-ken, Japan Witness: Type:

NOTES: MUST BE DATED.

Takayuki NIUYA

**INVENTOR: SIGNATURE** 

WITNESS DESIRABLE.

LEGALIZATION NOT REQUIRED.

**RECORDING OFFICER:** 

After recording, please return to:

FRISHAUF, HOLTZ, GOODMAN, LANGER & CHICK, P.C. 767 Third Avenue - 25th Floor, New York, N.Y. 10017-2023 Tel. No.: (212) 319-4900 Fax No.: (212) 319-5101

PATENT

REEL: 009953 FRAME: 0832

## **ASSIGNMENT**

INVENTOR:SIGNATURE	DATE	ADDRESS	
Sign:	Date:	Address:	
Tetous asyama	Apr. 30, 1999	c/o Mitsubishi Cas Chemical Company, Inc., Niigata Research Laboratory, 182, Aza-Shinwari, Tayuhama, Niigata-shi, Niigata-ken, Japan	
Type: Tetsuo AOYAMA	Witness:		
Sign:	Date:	Address:	
Taketo Maryama	Apr. 30, 1999	c/o Mitsubishi Cas Chemical Company, Inc., Niigata Research Laboratory, 182, Aza-Shinwari, Tayuhama, Niigata-shi, Niigata-ken, Japan	
Type: Taketo MARUYAMA	Witness:		
Sign: 7	Date:	Address:	
Telsuya Zarita	Apr. 30, 1999	c/o Mitsubishi Cas Chemical Company, Inc., Nigata Research Laboratory,	
Type: Tetsuya KARITA	Witness:	182, Aza-Shinwari, Tayuhama, Niigata-shi, Niigata-ken, Japan	
Sign:	Date:	Address:	
Kojin Alve	Apr. 30, 1999	c/o Mitsubishi Cas Chemical Company, Inc., Niigata Research Laboratory, 182, Aza-Shinwari, Tayuhama, Niigata-shi, Niigata-ken, Japan	
Type: Kojiro ABE	Witness:		
Sign:	Date:	Address:	
Tuknaduron (lehihara	Apr. 30, 1999	c/o Mitsubishi Cas Chemical Company, Inc., Corporate Research Laboratory,	
Type: Fukusaburou ISHIHARA	Witness:	22, Wadai, Tsukuba-shi, Ibaraki-ken, Japan	
Sign:	Date:	Address:	
Ryuji Sotoaka	Apr. 30, 1999	c/o Mitsubishi Cas Chemical company, Inc., Corporate Research Laboratory, 22, Wadai, Tsukuba-shi, Ibaraki-ken, Japan	
Type: Ryuji SOTOAKA	Witness:		
Sign:	Date:	Address:	
- ig	Vale.		
Type:	Witness:		
Sign:	Date:	Address:	
Type:	Witness:		

**RECORDED: 05/10/1999** 

PATENT REEL: 009953 FRAME: 0833